

UNIVERSITY OF CALIFORNIA, BERKELEY
DEPARTMENT OF ELECTRICAL ENGINEERING AND COMPUTER
SCIENCES

EECS 130

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Fall 2009

Midterm II Solutions

Name: _____

SID: _____

Closed book. Two sheets of notes are allowed.

*There are **10** pages of this exam including this page.*

| | |
|-----------|-----|
| Problem 1 | 25 |
| Problem 2 | 20 |
| Problem 3 | 30 |
| Problem 4 | 25 |
| Total | 100 |

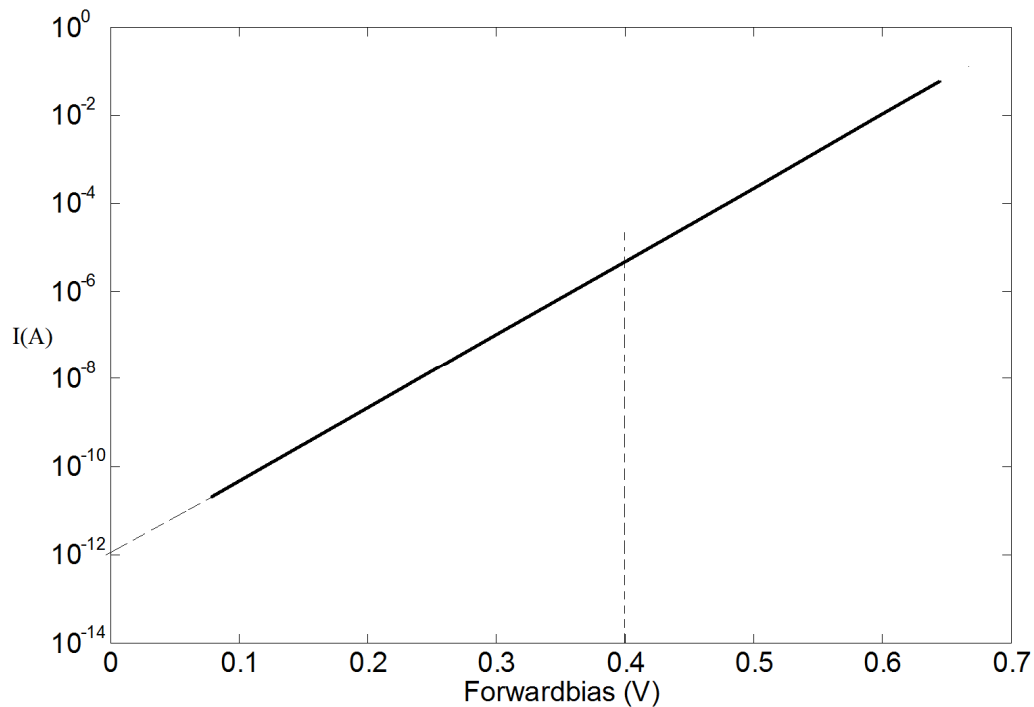
Physical Constants

| | | |
|---|------------------------------|---|
| Electronic charge | q | $1.602 \times 10^{-19} \text{ C}$ |
| Permittivity of vacuum | ϵ_0 | $8.845 \times 10^{-14} \text{ F}\cdot\text{cm}^{-1}$ |
| Relative permittivity of silicon | ϵ_s / ϵ_0 | 11.8 |
| Relative permittivity of SiO ₂ | $\epsilon_{ox} / \epsilon_0$ | 3.9 |
| Boltzmann's constant | k | $8.617 \times 10^{-5} \text{ eV}\cdot\text{K}^{-1}$ or $1.38 \times 10^{-23} \text{ J}\cdot\text{K}^{-1}$ |
| Thermal voltage at $T = 300\text{K}$ | kT/q | 0.026V |
| Effective density of states | N_{c_Si} | $2.8 \times 10^{19} \text{ cm}^{-3}$ |
| Effective density of states | N_{v_Si} | $1.04 \times 10^{19} \text{ cm}^{-3}$ |
| Silicon Band Gap | E_{g_Si} | 1.12eV |
| Intrinsic carrier concentration of Si at 300K | n_{i_Si} | $1.5 \times 10^{10} \text{ cm}^{-3}$ |
| GaAs Band Gap | E_{g_GaAs} | 1.42eV |

(Assume T=300K unless otherwise mentioned)

1. Small Signal Model of P⁺N Diode

(a) (3Pts) Find the I_0 (reverse saturation current) of the diode from the figure below.



Since PN junction I-V relation $I = I_0(\exp(V/(kT/q))-1)$ is exponential when V is larger than a few kT/q , the curve is linear with a slope of 60mV/dec in semilogy plot. Extrapolating the I-V curve to intersect the y-axis ($V_{forward}=0$) you will get $I_0 = 1pA$.

(Some students mistakenly treat $\log I(A)$ as the value of y axis coordinate, and double count log. Since the plot in the exam is not completely clear, full credits are given as long as we see extrapolation, 1e-12A or a reasonable way to get I_0 in your answer.)

(b) (3Pts) At a forward bias of 0.4V, what is the small signal conductance of the P⁺N junction?

$$I(V_{forward} = 0.4V) = I_0 \cdot [\exp(q \cdot V_{forward}/kT) - 1] = 4.802 \mu A.$$

$$G = dI/dV = q \cdot I/(kT) = 4.802 \mu A / 0.026V = 1.85 \times 10^{-4} \Omega^{-1}$$

(I@Vforward=0.4V can also be found in the plot in (a), which is around 5 μ A. Some students get the wrong numerical answer because of the wrong value of I_0 in (a). We give full credits if we see $G = qI/(kT)$.)

(c) (3Pts) At the bias in (b), to achieve a small signal capacitance of 5nF, what should the charge-storage time (τ_s) of the diode be?

$$\text{Diffusion Capacitance, } C = dQ/dV = \tau_s \cdot dI/dV = \tau_s \cdot G$$

=> charge-storage time, $\tau_s = C / G = 27.07 \mu s$

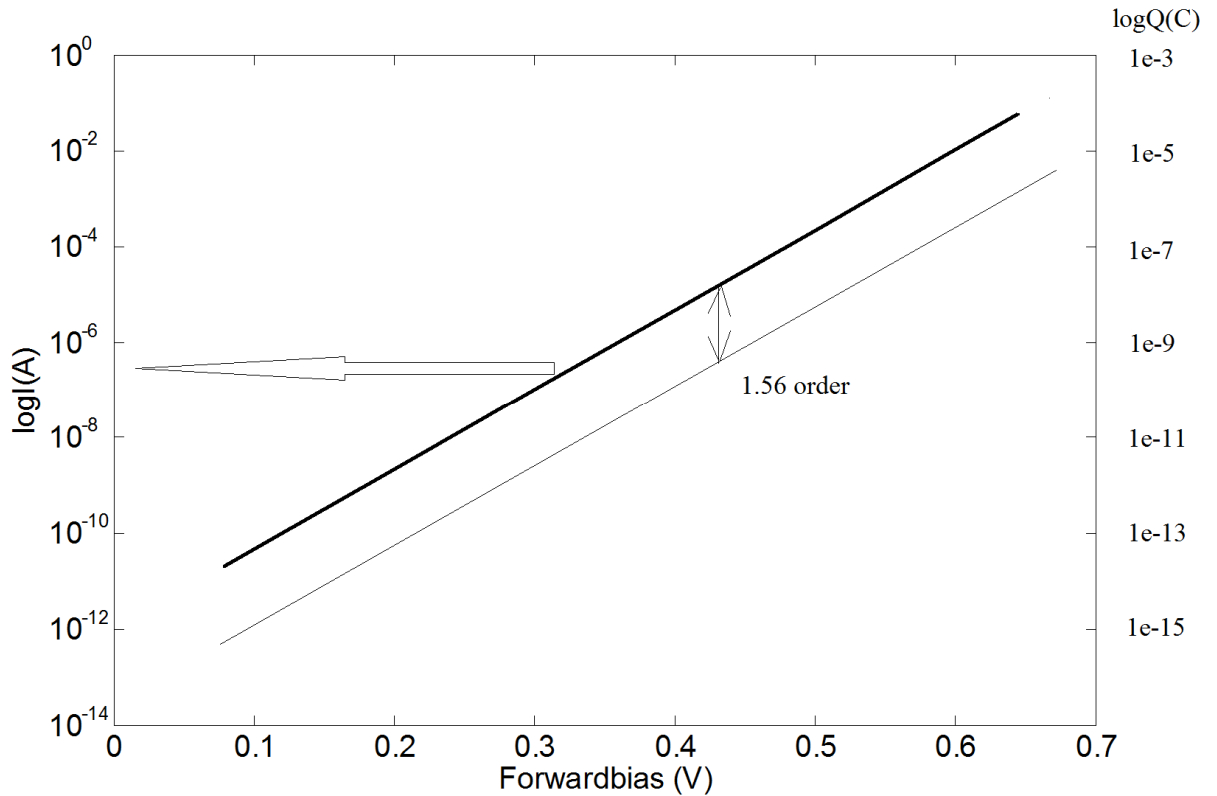
(Again, since (b) and (c) are coupled, full credits are given if we see $\tau_s = C / G$.)

(d) (3Pts) Draw the stored charge Q_s vs. Bias (V_{forward}) in the figure below.

$$Q_s = I \cdot \tau_s$$

$$\Rightarrow \log(Q_s) = \log(I) + \log(\tau_s) \sim \log(I) + 10^{-4.567}$$

\Rightarrow a line parallel to I ... shifted by 4.567 orders below, since y axis on the right is already 3 orders lower than the left y axis, only need to shift down by about 1.567 orders, represented below.



(parallel: 1pt, shift down: 1pt, order between 1 to 2: 1pt)

(e) (4Pts) Suppose the doping, $N_d = 1e17 \text{ cm}^{-3}$, estimate the depletion layer thickness under 0.4V of forward bias.

$$\text{Built in potential, } \phi_{bi} = E_g/2 + (kT/q) \cdot \ln(N_d/n_i) = 0.56 + 0.419 = 0.979 \text{ V.}$$

$$\text{Depletion thickness, } W_{dep} = \sqrt{\frac{2 \cdot \epsilon_0 \cdot \epsilon_{Si} \cdot (\phi_{bi} - V_A)}{q \cdot N_d}} = 86.53 \text{ nm}$$

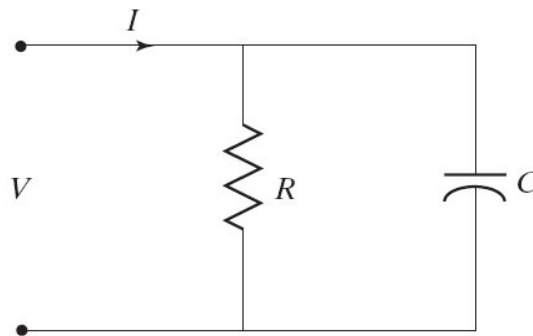
(Those of you who end up with $\phi_{bi}=0.419V$ should pay attention to the way to calculate ϕ_{bi} , especially when one side is heavily doped. Also you should know when it's forward biased, the potential drop across the junction should be $\phi_{bi} - V_A$.)

- (f) **(3Pts)** What is the depletion capacitance at this bias? Is it smaller or larger compared to the diffusion capacitance given in (c)? Assume diode cross-section area = 0.01 cm^2 .

$$C_{dep} = A \cdot \epsilon_0 \cdot \epsilon_{Si} / W_{dep} = 1.197 \text{ nF} < \text{Diffusion Capacitance, } C.$$

(In reality, Diffusion Capacitance should be much larger than C_{dep} when moderately forward biased. Again, since (e) and (f) are coupled, we give full credits if we see the right equation.)

- (g) **(3Pts)** Draw the RC equivalent circuit of the diode.



- (h) **(3Pts)** Calculate the RC time constant of the diode.

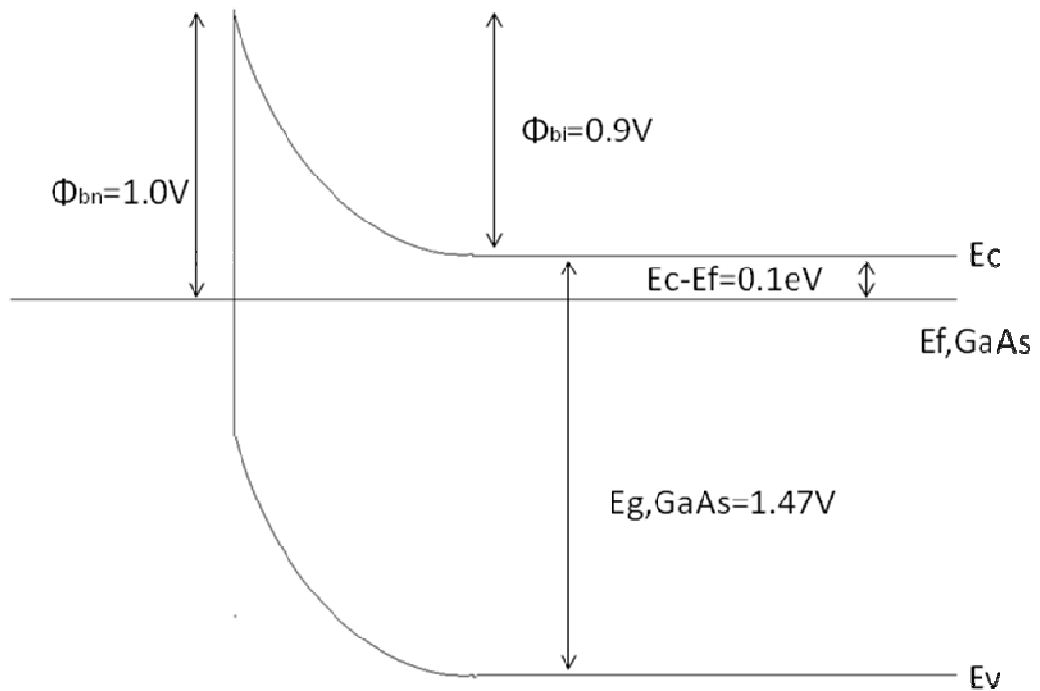
$$\tau = R.C = C/G = \tau_s = 27.07 \mu s$$

(τ has to be self-consistent with the τ_s in (c) or slightly larger because of adding C_{dep} in parallel with $C_{diffusion}$)

2. GaAs Schottky diode and MESFET

- (a) **(5Pts)** GaAs has $E_g=1.47\text{eV}$, $N_c=4.7 \times 10^{17} \text{ cm}^{-3}$. Given $\phi_{Bn}=1.0V$, doping concentration $N_d=10^{16} \text{ cm}^{-3}$, draw the energy diagram for this diode at zero bias condition. Label (Fermi level) E_F and (Built-in potential) ϕ_{bi} .

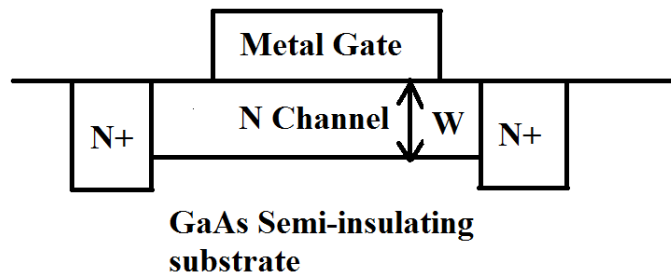
$$\phi_{bi} = \phi_{Bn} - (kT/q) \cdot \ln(N_c/N_d) = 1.0 - 0.1 = 0.9 \text{ V}$$



(b) (2Pts) What is the depletion layer thickness, W_{dep} ? ($\epsilon_{GaAs} = 13$)

$$Depletion\ thickness, W_{dep} = \sqrt{\frac{2 \cdot \epsilon_0 \cdot \epsilon_{GaAs} \cdot (\phi_{bi})}{q \cdot N_d}} = 0.36 \mu m$$

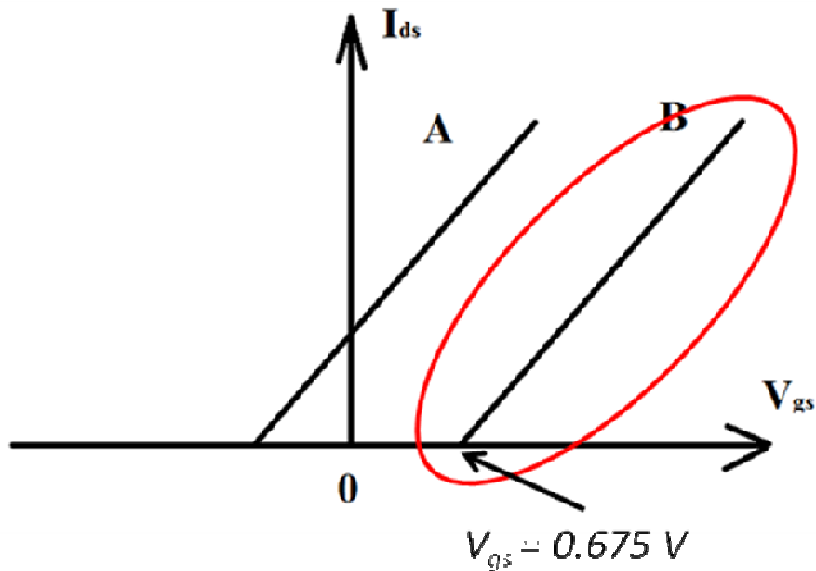
(c) (5Pts) Shown below is the structure of a MESFET. What is the maximum value of channel thickness, 'W' that will result in an enhancement-mode transistor?



Enhancement mode => Channel is 'off' at $V_g = 0V$ => N Channel is atleast fully-depleted for $V_g = 0V$ => maximum $W = W_{dep}$. For any value greater than W_{dep} the channel would be partially depleted thus allowing current to conduct at $V_g = 0V$.
So maximum $W = W_{dep} = 0.36 \mu m$

- (d) (4Pts) Which I-V curve below do you think is the right characteristic for a MESFET that has one-half the channel width of that in (c)? Explain in one statement.

Half the channel width => it is indeed enhancement mode ... and would switch on only for some positive applied gate bias V_g ... when the depletion width reduced to less than half => curve B



- (e) (4Pts) Find the value of V_{gs} where this transistor (in (d)) turns from off to on and show it on the plot too.

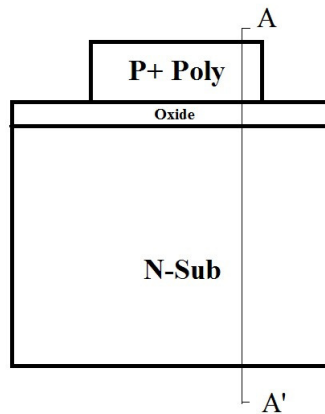
$$W_{channel} = W_{dep} / 2 = 0.18 \mu m$$

$$\text{So transistor turns on for, } W_{dep}(V_{gs}) = W_{dep}(V_{gs}=0) / 2 = \sqrt{\frac{2 \cdot \epsilon_0 \cdot \epsilon_{GaAs} \cdot (\phi_{bi} - V_{gs})}{q \cdot N_d}}$$

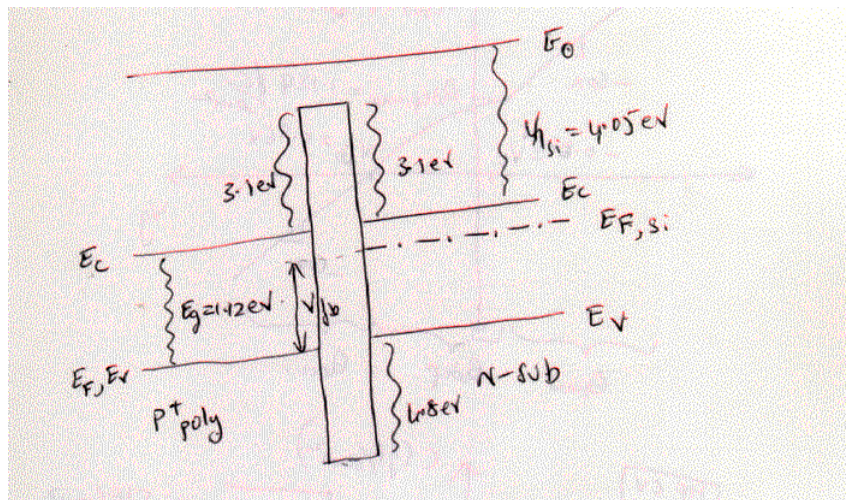
$$\Rightarrow V_{gs} = 0.675 V$$

(Again, forward bias means a minus in the formula.)

3. P+ Poly/ N-substrate MOSCAP



(a) **(5Pts)** Sketch the energy band diagram along the line A-A' at flat-band voltage.



Sorry for the tilted figure :D

Not looking for E_0 and band-offset values

Showing E_C, E_V essentially flat and a larger band-gap oxide – **2Pts**

Labels $E_C, E_V, E_{F, Si}, E_{F, Poly}$ --- **2Pts**

Indicating V_{fb} --- **1Pt**

(b) **(4Pts)** Calculate the threshold voltage, given that $V_{fb}=0.96V$, $C_{OX}=2fF/\mu m^2$, $2\phi_B=0.8V$, $Q_{dep_max}=qN_{sub}W_{dmax}=1 fC/\mu m^2$. (Ignore Poly-Depletion)

$$V_t = V_{fb} - 2\phi_B - Q_{dep_max}/C_{ox} = 0.96 - 0.8 - 0.5 = -0.34V$$

(It's OK if you used different values)

Formula --- **2Pts**

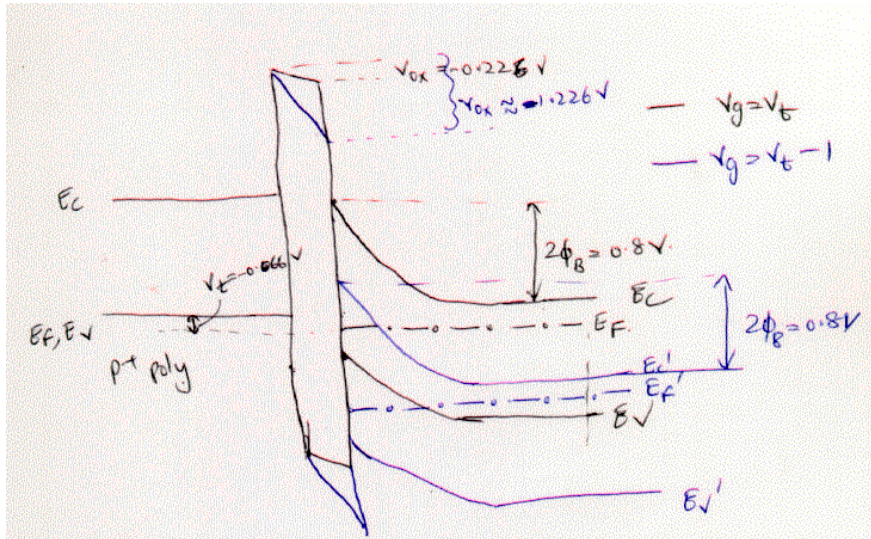
Consistent Answer --- **2Pts**

Plots for questions further should be consistent with the answer you have got here.

(c) (5Pts) Draw energy band diagram at $V_g = V_t$ and $V_g = V_t - 1V$, show both diagrams on the same sketch and clearly show their differences.

At $V_g = V_t$... band-bending in substrate $= 2\phi_B = 0.8V$; and $V_{ox} = -0.5V$

At $V_g = V_t - 1V$... MOSCAP in inversion ... band-bending in substrate stays the same $= 2\phi_B = 0.8V$; all the voltage drops appears in the oxide, $V_{ox} = -1.5V$



In above figure replace $V_{ox} = -0.5V$ and $V_{ox} = -1.5V$ and $V_t = -0.34V$

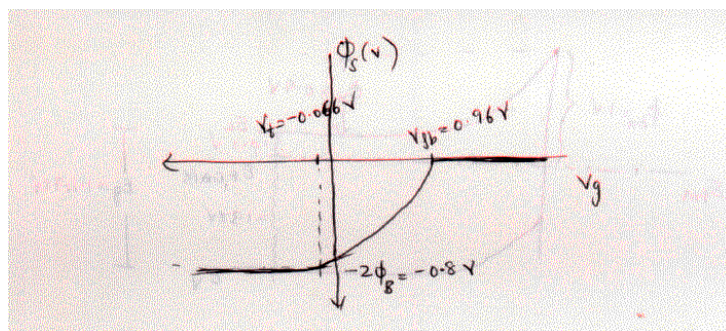
$V_g = V_t$ figure ... showing band-bending correctly --2Pts

Labels ---1 Pt

$V_g = V_t - 1V$ overlaid showing band-bending correctly ---2Pts

I am necessarily looking for some sort of indication that the MOSCAP is into inversion

(d) (4Pts) Plot the surface potential, ϕ_s vs. V_g

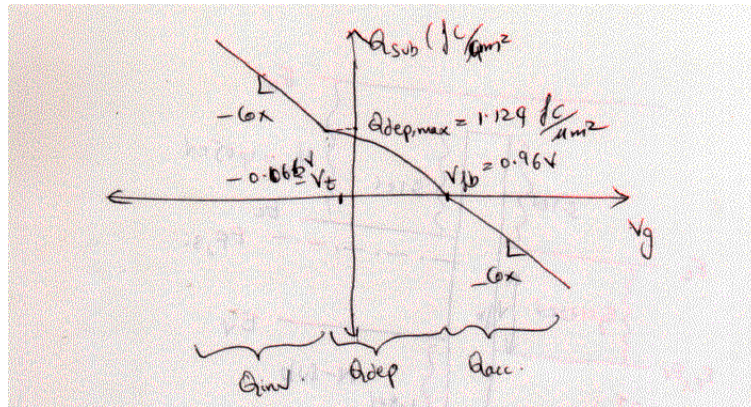


In above figure V_t should be $-0.34V$

Correct Plot -- 3Pts (Positive ϕ_s is OK ... provided inversion is for $V_g < V_t$)

Label --1Pt

(e) (4Pts) Plot the substrate charge, $Q_{sub} (= Q_{acc} + Q_{dep} + Q_{inv})$ vs. V_g



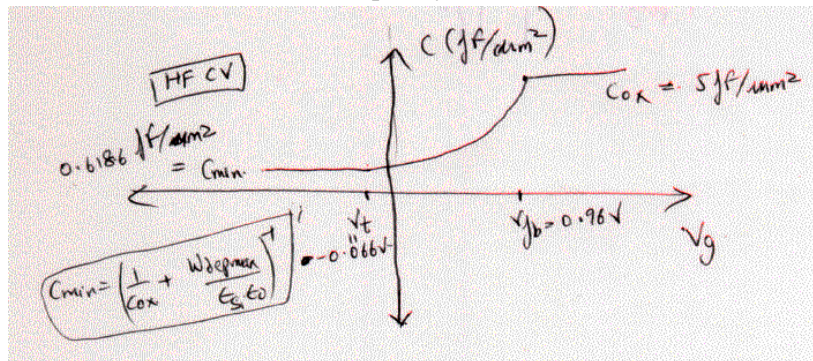
In above figure V_t should be $-0.34V$ and $Q_{dep,max} = 1fC/\mu m^2$

Correct Plot ---2Pts (Will not give points if drawn for P-Substrate)

Basic labels .. V_{fb} , V_t ---1Pt

Advance labels ... $Q_{dep,max}$, slopes etc ...--1Pt

(f) (4Pts) Sketch C-V of the MOSCAP at a frequency, $f=10MHz$.



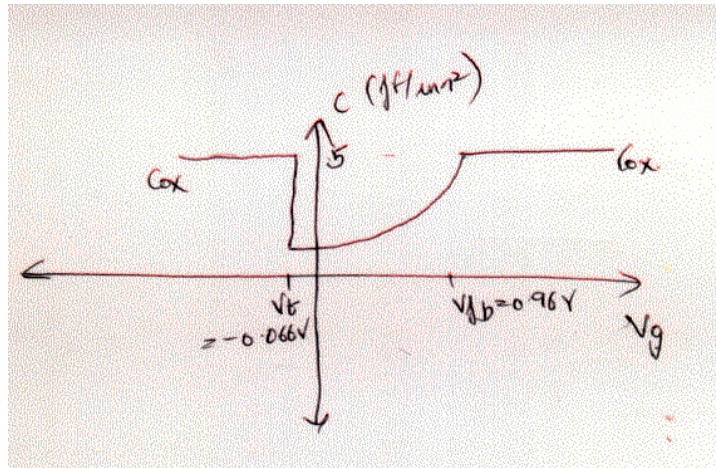
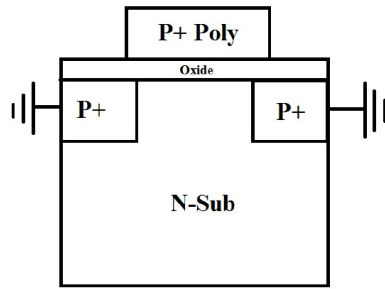
In above figure V_t should be $-0.34V$; $C_{ox} = 2fF/\mu m^2$ and $C_{min} = 0.57 fF/\mu m^2$

Correct Plot ---2Pts (Will not give points if drawn for P-Substrate)

Basic labels .. V_{fb} , V_t ---1Pt

Advance labels .. C_{ox} and C_{min} etc ...--1Pt (Not looking for C_{min} value)

(g) (4Pts) After applying P+ implantation to form a MOSFET below, plot C-V again at $f=10MHz$.

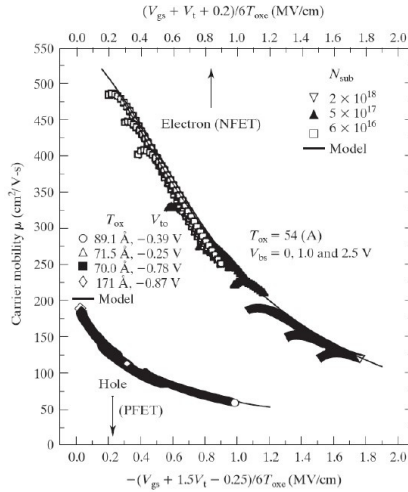


In above figure V_t should be $-0.34V$; $C_{ox} = 2fF/\mu m^2$; $C_{min}=0.57fF/\mu m^2$
 Correct Plot ---**2Pts** (Will not give points if drawn for P-Substrate)
 Basic labels .. V_{fb} , V_t ---**1Pt**
 Advance labels ... C_{ox} , C_{min} etc ... ---**1Pt**

4. MOSFET I-V

Given an N-Channel MOSFET of $W=100\mu\text{m}$, $L=1\mu\text{m}$, $V_{t0}=0.5\text{V}$, $W_{\text{dep,max}} = 30\text{nm}$, $T_{\text{oxe}}=5\text{nm}$, $V_{\text{gs}}=2.0\text{V}$.

- (a) (4Pts) What is the value of channel mobility, μ_{ns} ? (You may need to consider mobility degradation)



Textbook formula estimate

$$\mu_{\text{ns}} = \frac{540\text{cm}^2/\text{Vs}}{1 + \left(\frac{V_{\text{gs}} + V_{t0} + 0.2}{5.4 * T_{\text{oxe}}} \right)^{1.85}} = 270\text{cm}^2/\text{Vs}$$

The term in the parenthesis should have units of MV/cm

Estimate from graph is also acceptable

Any acceptable estimate –4Pts

- (b) (4Pts) Determine the source to drain current, I_{ds} at $V_{\text{ds}}=0.8\text{V}$?

$$V_{\text{dsat}} = (V_{\text{gs}} - V_{t0})/m = (2.0 - 0.5)/1.5 = 1.0\text{V} > V_{\text{ds}} = 0.8\text{V} \Rightarrow \text{Linear region}$$

$$m = 1 + 3 * T_{\text{oxe}} / W_{\text{d max}} = 1 + 15/30 = 1.5$$

$$I_{\text{ds}} = \frac{W}{L} C_{\text{oxe}} \cdot \mu_{\text{ns}} \cdot (V_{\text{gs}} - V_{t0} - \frac{m}{2} V_{\text{ds}}) V_{\text{ds}} = \frac{100}{1} \times \frac{\epsilon_0 \cdot \epsilon_{\text{ox}}}{T_{\text{oxe}}} \times 270 \times 0.9 \times 0.8 = 13.42\text{mA}$$

Calculating 'm' --1Pt, Identifying Linear region – 1Pt, I_{ds} formula and value – 2Pts

- (c) (4Pts) What is the current, I_{ds} at $V_{\text{ds}}=2.0\text{V}$?

$$V_{\text{dsat}} = (V_{\text{gs}} - V_{t0})/m = (2.0 - 0.5)/1.5 = 1.0\text{V} < V_{\text{ds}} = 2.0\text{V} \Rightarrow \text{Saturation region}$$

$$m = 1 + 3 * T_{\text{oxe}} / W_{\text{d max}} = 1 + 15/30 = 1.5$$

$$I_{\text{ds}} = I_{\text{dsat}} = \frac{W}{2mL} C_{\text{oxe}} \cdot \mu_{\text{ns}} \cdot (V_{\text{gs}} - V_{t0})^2 = \frac{100}{3} \times \frac{\epsilon_0 \cdot \epsilon_{\text{ox}}}{T_{\text{oxe}}} \times 270 \times 1.5 \times 1.5 = 13.98\text{mA}$$

Identifying Saturation region – 2Pts, I_{ds} formula and value – 2Pts

- (d) **(4Pts)** Determine the threshold voltage, V_t when the body-source junction is reverse-biased by 1.0V?

$$V_t (V_{sb}=1V) = V_{t0} + (m-1) \cdot V_{sb} = 0.5 + 0.5 \cdot 1 = 1V$$

Using correct formula – **2Pts**, Calculation – **2Pts**

- (e) **(4Pts)** What is the mobility, μ_{ns} under the new condition in (d)?

Textbook formula estimate

$$\mu_{ns} = \frac{540 \text{cm}^2 / \text{Vs}}{1 + \left(\frac{V_{gs} + V_t + 0.2}{5.4 \cdot T_{oxe}} \right)^{1.85}} = 227.95 \text{cm}^2 / \text{Vs}$$

Note the use of V_t instead of V_{t0}

Estimate from graph is also acceptable

*Identifying usage of V_t instead of V_{t0} – **2Pts**, Estimate of mobility – **2Pts***

- (f) **(5Pts)** Calculate I_{ds} at $V_{ds}=0.8V$ for this new condition?

$$V_{dsat} = (V_{gs} - V_t) / m = (2 - 1) / 1.5 = 0.667V < V_{ds} = 0.8V \Rightarrow \text{Saturation region}$$

$$I_{ds} = I_{dsat} = \frac{W}{2mL} C_{oxe} \cdot \mu_{ns} \cdot (V_{gs} - V_t)^2 = \frac{100}{3} \times \frac{\epsilon_0 \cdot \epsilon_{ox}}{T_{oxe}} \times 270 \times 1.0 \times 1.0 = 6.2133 \text{mA}$$

*Identifying Saturation region – **3Pts**, I-V --- **2Pts***